CLAIMS

1. (Currently amended) A lamination ceramic chip inductor, formed by the process comprising the steps of:

interposing at least one <u>a</u> conductive pattern between at least one <u>a</u> pair of insulation layers so as to be in contact with at least one of the pair of insulation layers; and forming a conductive coil,

wherein the interposing step includes electroforming at least one conductive pattern, and the conductive pattern has a thickness of 10 μ m or more and a width to thickness ratio from 1 to less than 5.

- 2. (Original) A lamination ceramic chip inductor according to claim 1, wherein the step of interposing at least one conductive pattern includes interposing a plurality of conductive patterns, and wherein the step further comprises printing a thick film conductor to electrically connect at least two of the conductive patterns to each other.
- 3. (Original) A lamination ceramic chip inductor according to claim 2, wherein the interposing step includes interposing an electroformed conductive pattern having a shape of a straight line.
- 4. (Original) A lamination ceramic chip inductor according to claim 1, wherein the interposing step includes interposing at least one conductive pattern between at least one pair of insulation layers which are magnetic.
- 5. (Original) A lamination ceramic chip inductor according to claim 1, wherein the interposing step includes interposing at least one conductive pattern between insulation layers formed of a material containing one of a non-shrinkage powder which

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does not shrink from sintering and a low ratio shrinkage powder which shrinks slightly from sintering.

- 6. (Previously amended) A lamination ceramic chip inductor according to claim 1, wherein the interposing step includes interposing the at least one conductive pattern between insulation layers formed of a magnetic material containing an organolead compound as an additive for restricting deterioration of magnetic characteristics of the insulating layers.
- 7. (Original) A lamination ceramic chip inductor according to claim 1, wherein the interposing step includes electroforming the conductive pattern of a silver plating liquid containing no cyanide.

16-27. (Canceled)